

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	65	(buried and oxide and polysilicon and base and source and drain and emitter and ("GaS" or "GaSe" or "GaTe" or "Ins" or "InSe" or "InTe" or "TIS")).clm.	US-PGPUB; USPAT	OR	ON	2005/08/04 16:08
L2	60	1 and @ad<"20030918"	US-PGPUB; USPAT	OR	ON	2005/08/04 16:09
L6	52584	(emitter with (GaS or GaSe or GaTe or Ins or InSe or InTe or TIS))	US-PGPUB; USPAT	OR	ON	2005/08/04 16:05
L7	52584	(emitter with ("GaS" or "GaSe" or "GaTe" or "Ins" or "InSe" or "InTe" or "TIS"))	US-PGPUB; USPAT	OR	ON	2005/08/04 16:05
L8	42415	7 and base	US-PGPUB; USPAT	OR	ON	2005/08/04 16:05
L9	231	8 and BiMOS	US-PGPUB; USPAT	OR	ON	2005/08/04 16:05
L10	229	9 and @ad<"20030918"	US-PGPUB; USPAT	OR	ON	2005/08/04 16:06
L11	1115	438/234,235,309,312.ccls.	US-PGPUB; USPAT	OR	ON	2005/08/04 16:09
L12	961	11 and @ad<"20030918"	US-PGPUB; USPAT	OR	ON	2005/08/04 16:10
L13	1694	257/197,200.ccls.	US-PGPUB; USPAT	OR	ON	2005/08/04 16:10
L14	1445	13 and @ad<"20030918"	US-PGPUB; USPAT	OR	ON	2005/08/04 16:10
L15	1326	14 not 12	US-PGPUB; USPAT	OR	ON	2005/08/04 16:10